No. 26 Taishan Road Suzhou New District Suzhou Jiangsu P.R. China

TAIYO INK (SUZHOU) CO., LTD.

Tel: +86-512-6665-5550 Fax: +86-512-6665-5057

Dual-component, alkaline developable Liquid photo imageable solder mask

PSR-4000 G23K / CA-40 G23K

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1. FEATURE:

PSR-4000 G23K / CA-40 G23K is a Photo imageable liquid solder mask ink (alkaline –developable type), designed for screen printing with wide process window, high photo speed and resolution, excellent resistance to gold plating (electro / electroless).

2. SPECTIFICATIONS:

Product name:	Main agent: PSR-4000 G23K	
1 Todact name.	Hardener: CA-40 G23K	
UL Name	Main agent:PSR-4000DE	
OL Name	Hardener:CA-40DE	
Color:	Main agent: Green	
Color.	Hardener: Milk white	
Mixing ratio:	Main agent: Hardener = 70: 30 (by wt.)	
Viscosity after mixing	150±20dPa.s (Cone-plate viscometer 5min ⁻¹ /25°C)	
Solid content:	79.0wt%	
Specific Gravity:	1.4 (after mixing)	
Tack dry window:	80°C×60min(Max)	
Г	200-400 mJ/cm² (Under Mylar film)	
Exposure:	140-280 mJ/cm ² (On solder mask)	
Post cure:	150℃×60min	
Pot life:	24 Hrs. (stored at dark & lustration place and closed, 25°C or below)	
Shelf life:	180 days after production (stored at dark place, 20°C or below)	

3. PROCESS CONDITIONS:

Process	Condition	Tolerance window
Test panels:	FR-4 (thickness 1.6mm)	-
Pretreatment:	Acid rinse → Buff scrubbing → Water rinse → Dry	-
Print:	100mesh	[100-125mesh]
Hold time	10 min	[10-20 min]
	A: double side printing using pin and double side exposure or single side exposure	[80°C 60min] (Max)
Pre-cure:	80°C 20-50min (Hot air convection oven)	
	B: two times printing and pre-cure for double side exposure	
	1 st : 80°C 10-25 min (Hot air convection oven)	
	2 nd : 80°C 20-35 min (Hot air convection oven)	
Exposure:	400 mJ/cm ² (Under Mylar film)	[200-400 mJ/cm ²]
	280 mJ/cm ² (On solder mask)	[140-280 mJ/cm ²]
	Halogen lamp 7kW (ORC HMW-680GW)	
Hold time:	10 min	[10-20 min]
Development:	Solution: 1wt% Na ₂ CO ₃	
	Temp. 30℃	
	Spray pressure 0.196Mpa	[0.196-0.245Mpa]
	Time: 60s	[60-100s]
Water rinse:	Temp. 25℃	[20-30℃]
	Spray pressure 0.1Mpa	[0.1-0.15Mpa]
	Time: 60s	[45-60s]
Post cure:	150℃ 60 min (Hot air convection oven)	[150°C 30-90 min]

4. ATTENTION ON PROCESS:

- a) As to operation environment, it is necessary to control temperature, humidity and dust. Please use the yellow lamp or Ultraviolet ray filter .Do not use the white lamp or sunlight.
- b) Incompetent mixing will cause quality problem, such as gloss uneven and post cure problem.
- c) The optimum coating thickness is 20 to 30 µm (after curing); Thinner coating tends to lower the thermal and gold plating resistance. Thicker coating tends to longer cure time and impress when exposure.
- d) If the viscosity is too high to print, can use some solvent such as Diethylene Glycol Monoethyle Ether Acetate (Carbitol Acetate), the quantity of the solvent can not exceed 2%, (one Kg ink can add 20cc solvent at best), otherwise, it may cause teardrop or lower resistance to thermal and gold plating.
- e) As every plant's drying equipments, process condition and quality target is different, so the temperature and drying time may also have difference. Please do verification test to define the operating conditions.
- f) As every plant's exposure equipments, process condition and quality target is different, so the exposure energy and development time may also have difference. Please do verification test to define the operating conditions.
- g) Please adjust the development solution, temperature, spray pressure and time follow this data to decrease the undercut and get the excellent result.
- h) Insufficient cure of the ink can lower the thermal resistance, and excess cure can lower gold plating resistance. Furthermore, Curing condition of the solder mask ink should be defined together with the curing condition of the marking ink.

CA: Diethylene glycol monomethyl ether acetate (B.P 217 deg. C)

5. INK PROPERTIES:

5.1 TACK DRY WINDOWS:

Drying time (80℃)	40min	50min	60min	70min
Developability	OK	OK	OK	OK

5.2 PHOTO SENSITIVITY:

Item	Thickness um	Under mylar film mJ/cm ²	On solder mask mJ/cm ²	Result
Sensitivity Kodak No.2		200	140	6step
	22±2	300	210	7step
		400	280	8step
Resolution Between QFP pads		200	140	50 um
	40±2	300	210	50 um
		400	280	50 um

(1 min development)

(1 min development)

6. PROPERTIES:

Item	Teat Method	Result
Adhesion	Taiyo internal method Cross hatch peeling	100 / 100
Pencil hardness	Taiyo internal method No scratch on copper	7 H
Thermal resistance	Rosin flux 260°C/10sec, 3cycles	Passed
Acid resistance	10vol% H ₂ SO ₄ 20°C/20min. (Dip) Tape peeling test	Passed
Alkaline resistance	10wt% NaOH 20°C/20min. (Dip) Tape peeling test	Passed
Solvent resistance	PGM-Ac 20°C/30min. (Dip) Tape peeling test	Passed
Insulation resistance	IPC comb type (B pattern) Humidification: 25-65°C/90%RH/ DC100V Cycling for 7 days Measurement: DC500V 1min.	Initial 1.0×10^{12} ohrm Conditioned 1.0×10^{10} ohrm
Dielectric constant	Taiyo internal method Values at 1MHz Humidification: 25-65°C/90%RH/ DC100V Cycling for 7 days	Initial 4.5 Conditioned 5.5
Dissipation factor	Taiyo internal method Values at 1MHz Humidification: 25-65°C/90%RH/ DC100V Cycling for 7 days	Initial 0.025 Conditioned 0.045
Electro gold plate	Internal lab test Ni 5um Au 1um	Passed
Electroless gold plate	Internal lab test Ni 3um Au 0.03um	Passed

Note:

- a) The above-mentioned data is based on TAIYO INK (SUZHOU) Company's laboratory test. As every plant's equipments, environment and parameters have difference, the data is only for your reference.
- b) Please work in accordance with MSDS.